



The eGaN[®] FET
Journey
Begins

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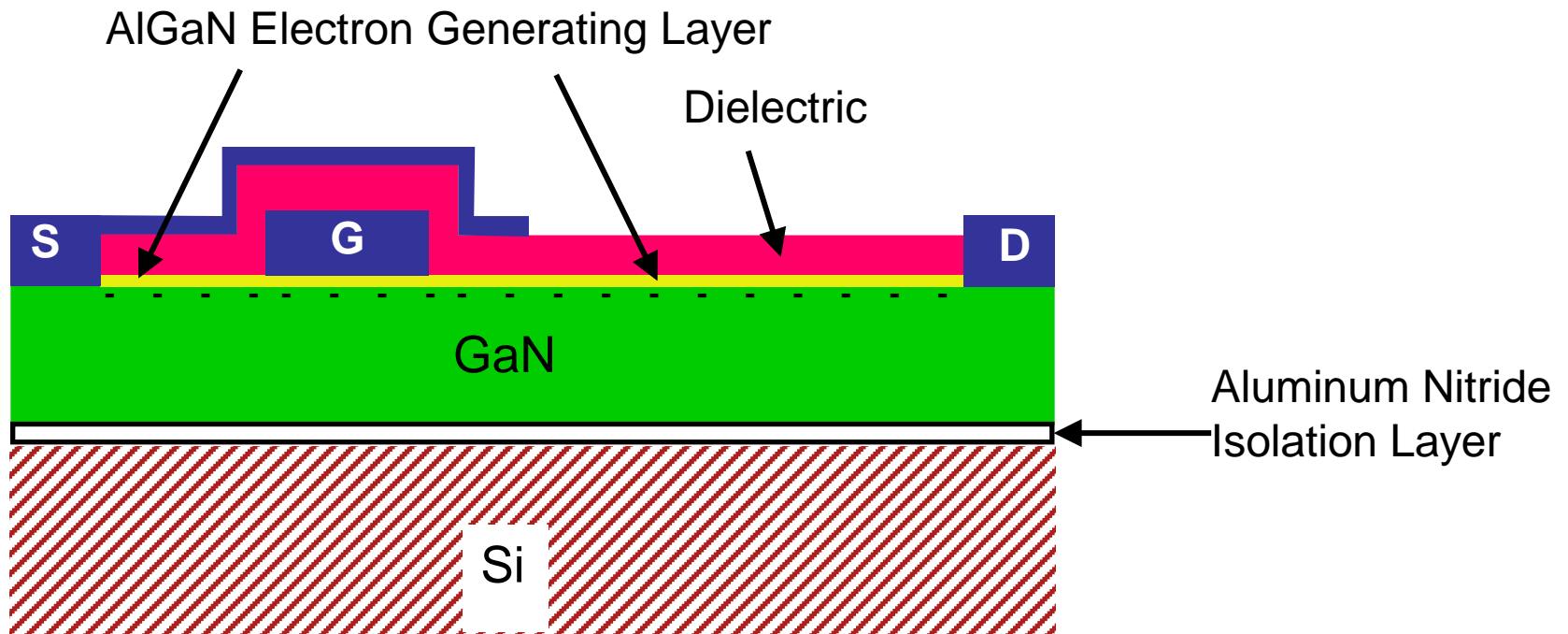
The intermediate bus architecture (IBA) is currently the most popular power system architecture in computing equipment. It typically consists of a +12 V system power distribution bus that feeds non-isolated, dc-dc converters. These non-isolated converters generate the low supply voltages required to power the various logic circuits. Because of their proximity to the circuits they power, these converters are commonly referred to as point-of-load converters (POLs).

Although the 12V IBA is widely used, it is coming under scrutiny. Some companies using a +12 V system power distribution bus with on-board bus converters and POLs are wondering if they can simplify their systems or improve system efficiency. For them, a single “POL” that converts the +48 V system bus directly to the load voltages is a very interesting idea. Until now, the technical limitations of the current silicon MOSFET technology and cost concerns have made it impractical to design such a POL and produce it commercially. However, recently introduced gallium-nitride (GaN) power devices have overcome these hurdles, making it feasible to build POLs with the high step down ratios needed to generate 1 V (or less) efficiently from a 48 V bus. These converters also offer significant improvement in board space and control bandwidth, but do not necessarily improve overall system efficiency. In this presentation we explore several choices for distribution buss voltage as well as multiple-stage DC-DC conversion. The conclusion is that the designer has many options to reduce cost, power losses, and board space by transitioning from power MOSFETs to eGaN FETs.

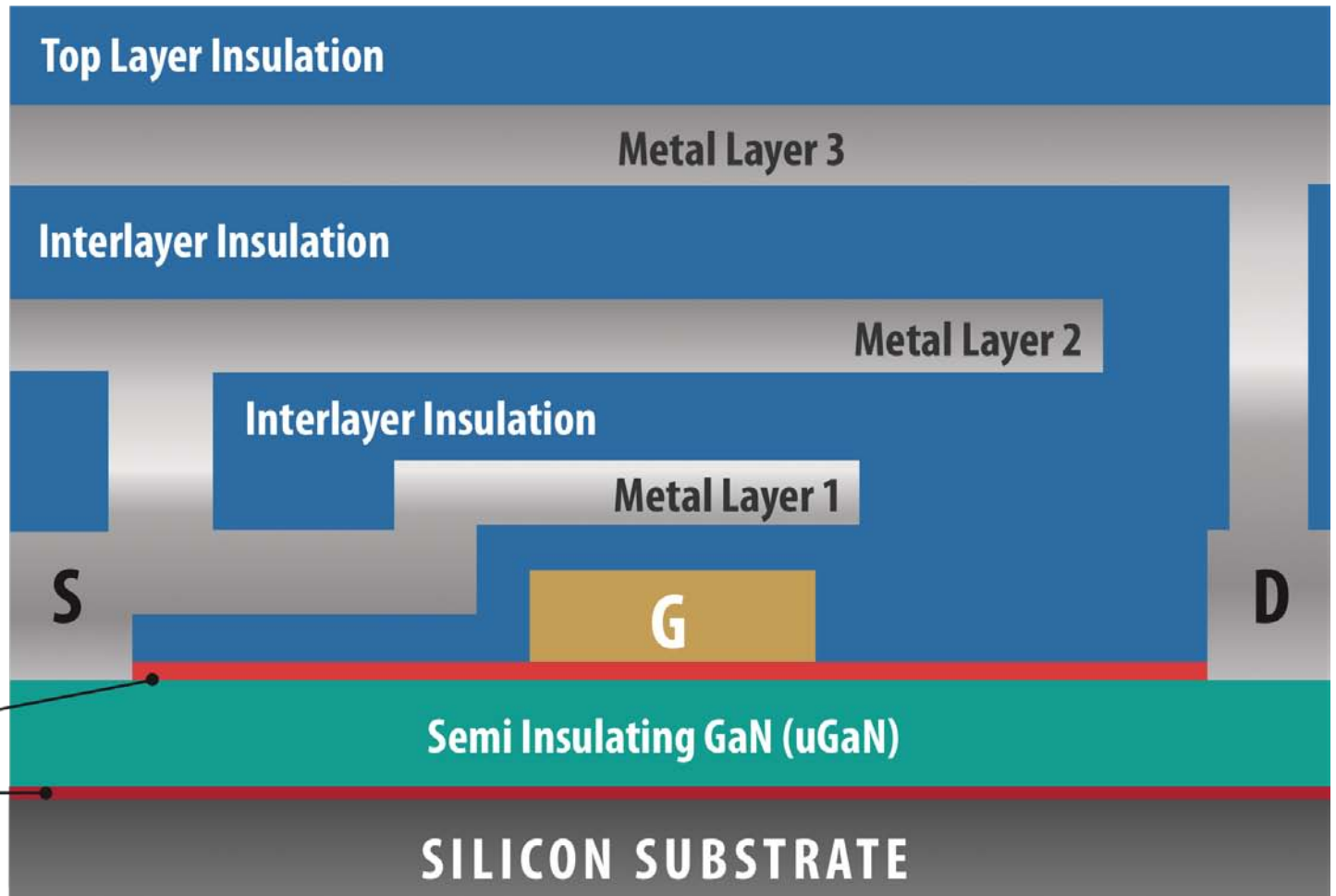
- **Overview of EPC *eGaN*[®] FET technology**
- **The opportunity to improve efficiency and performance**
- **Future Products**
- **Conclusions**

Overview of eGaN FET[®] Technology

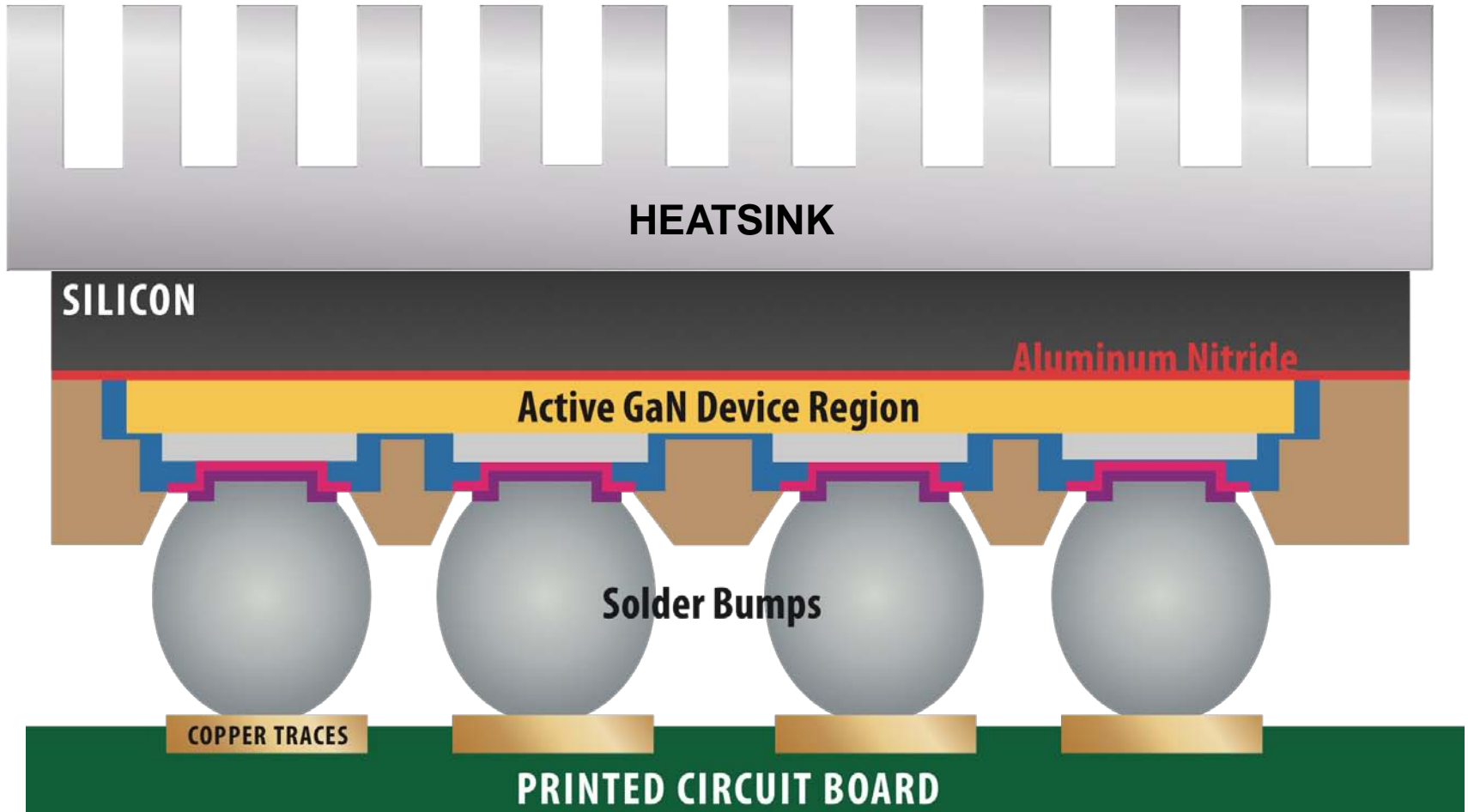
eGaN FETs Structure



eGaN FETs Structure

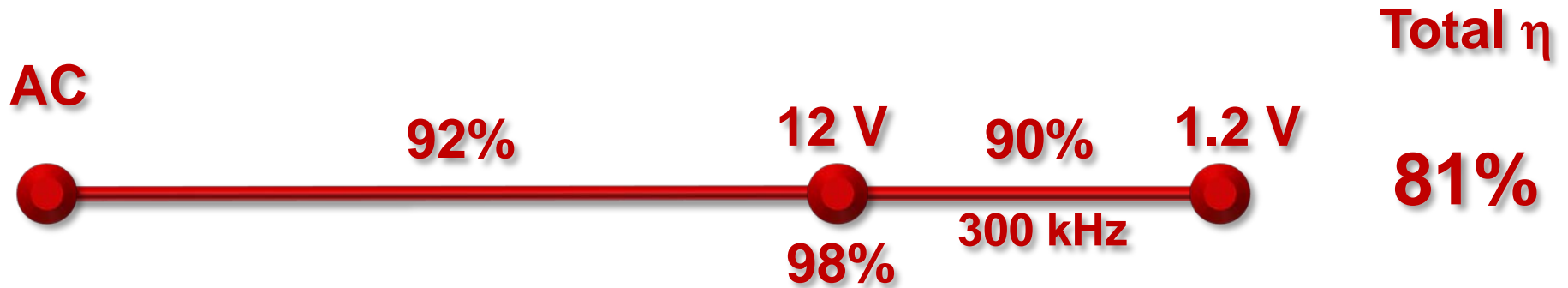


Flip Chip Assembly



The Opportunity to Improve Efficiency

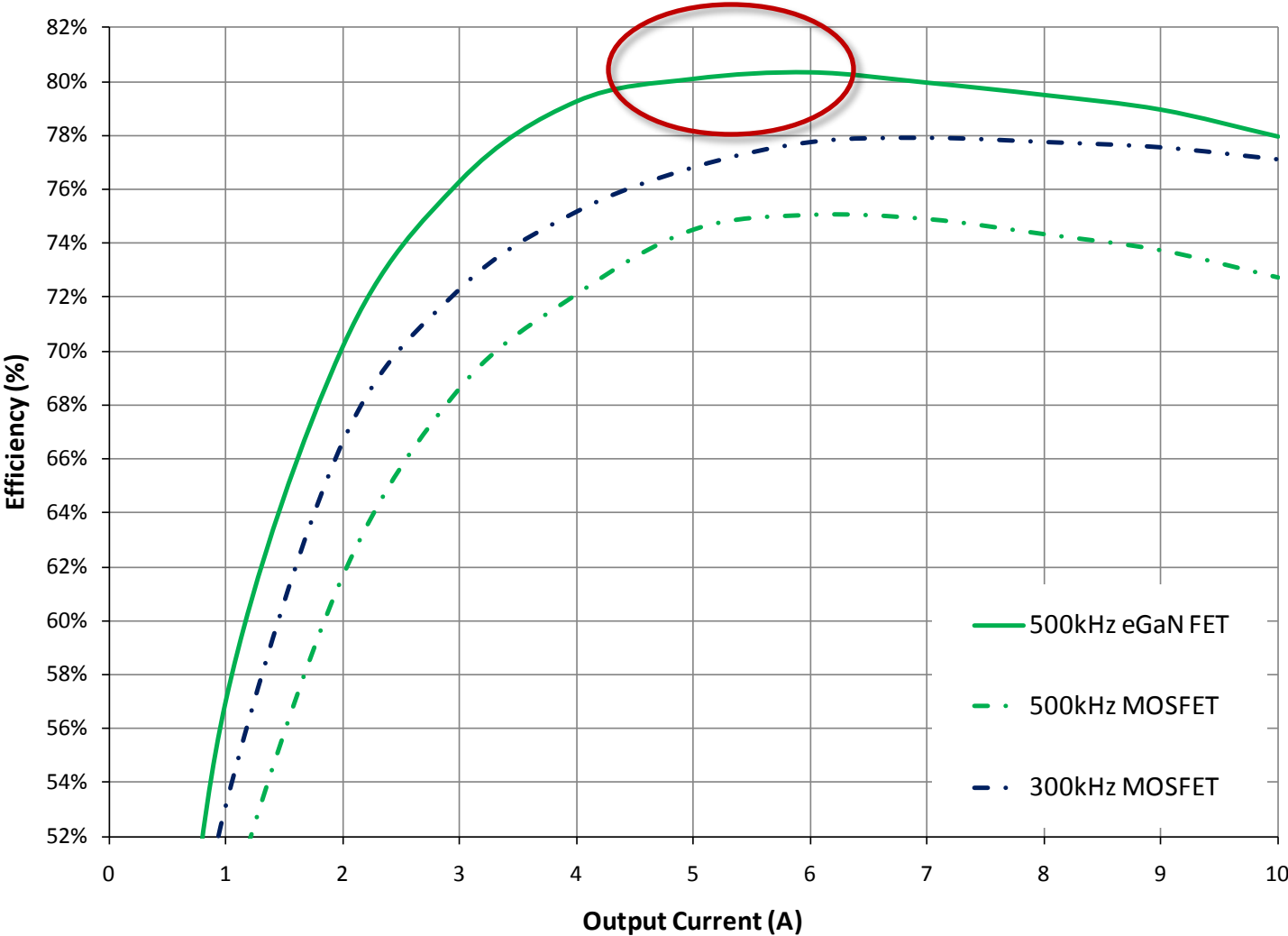
Efficiency Comparisons



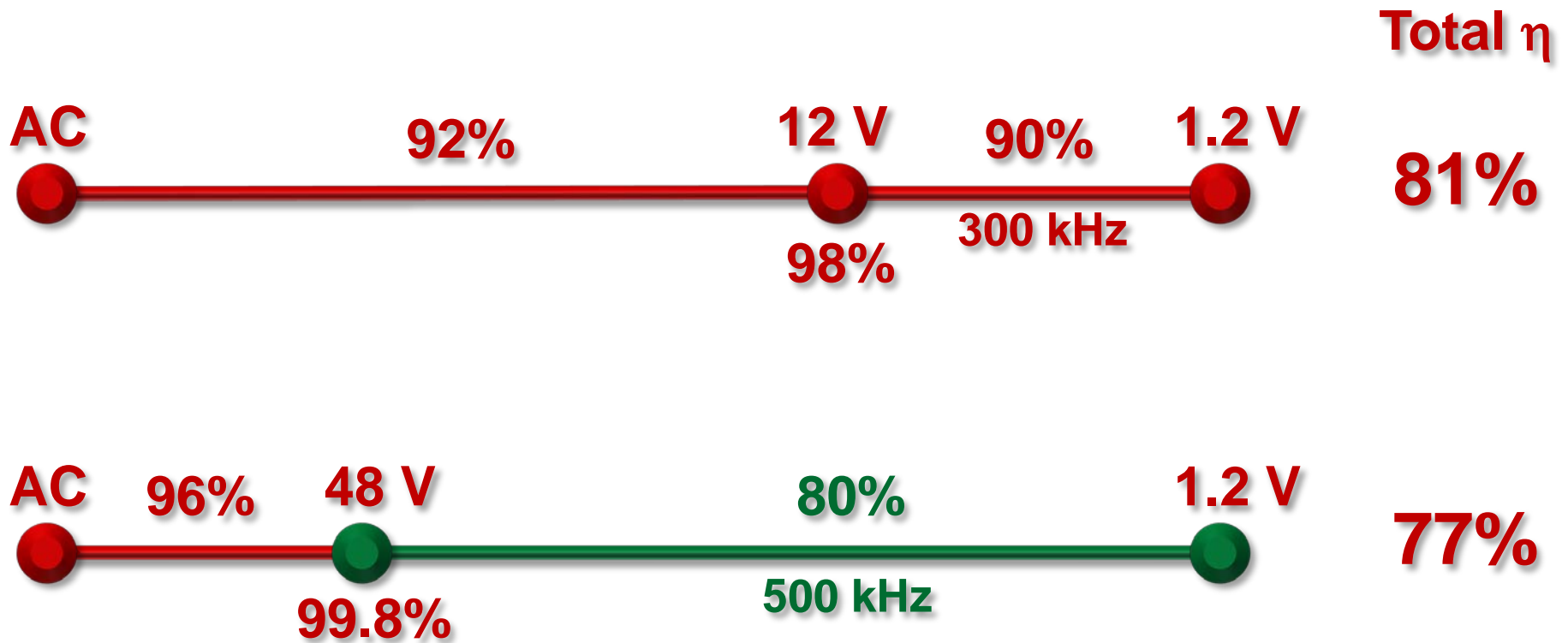
eGaN FETs vs Power MOSFETs



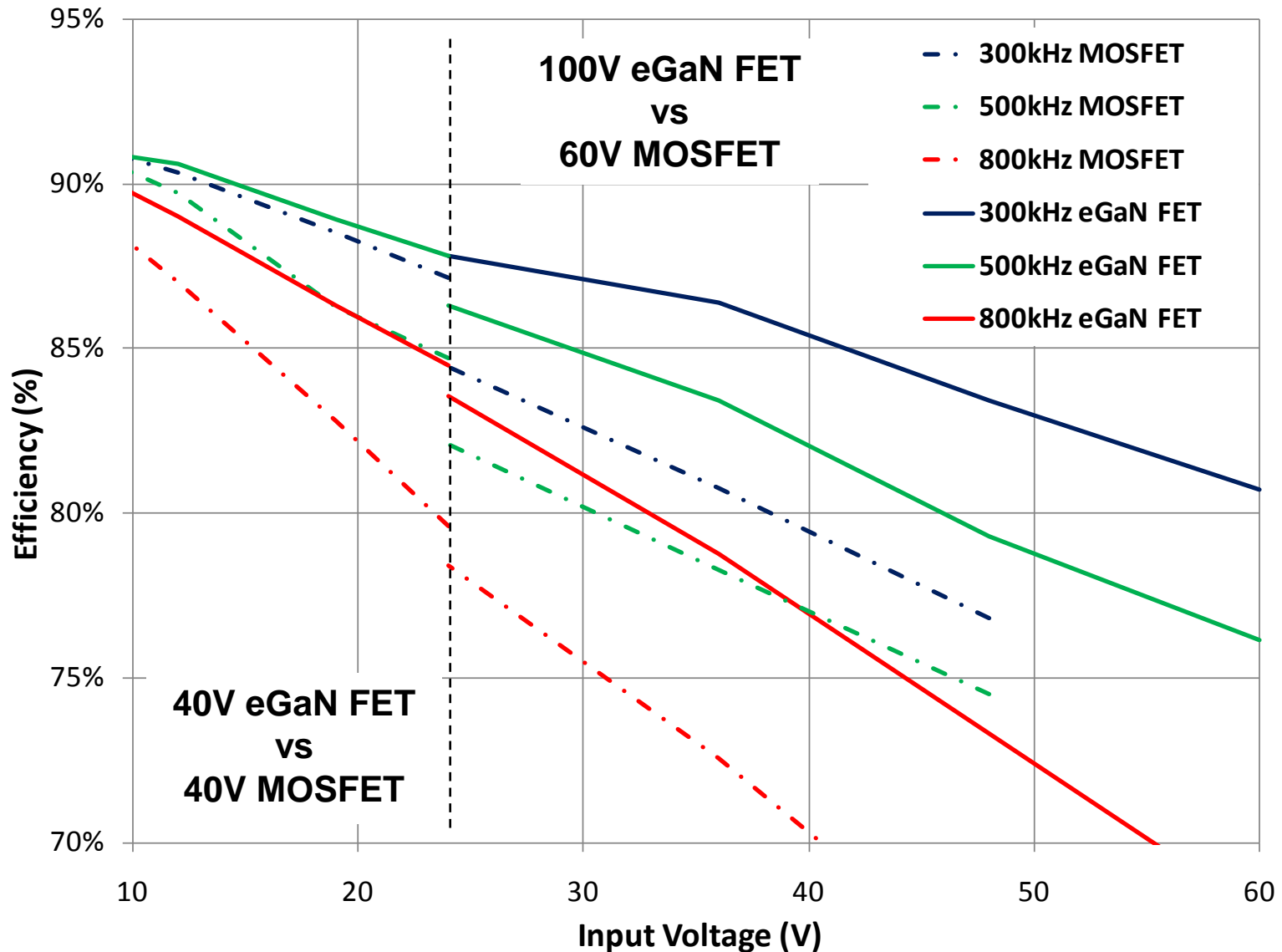
48V - 1.2V Efficiency Comparison



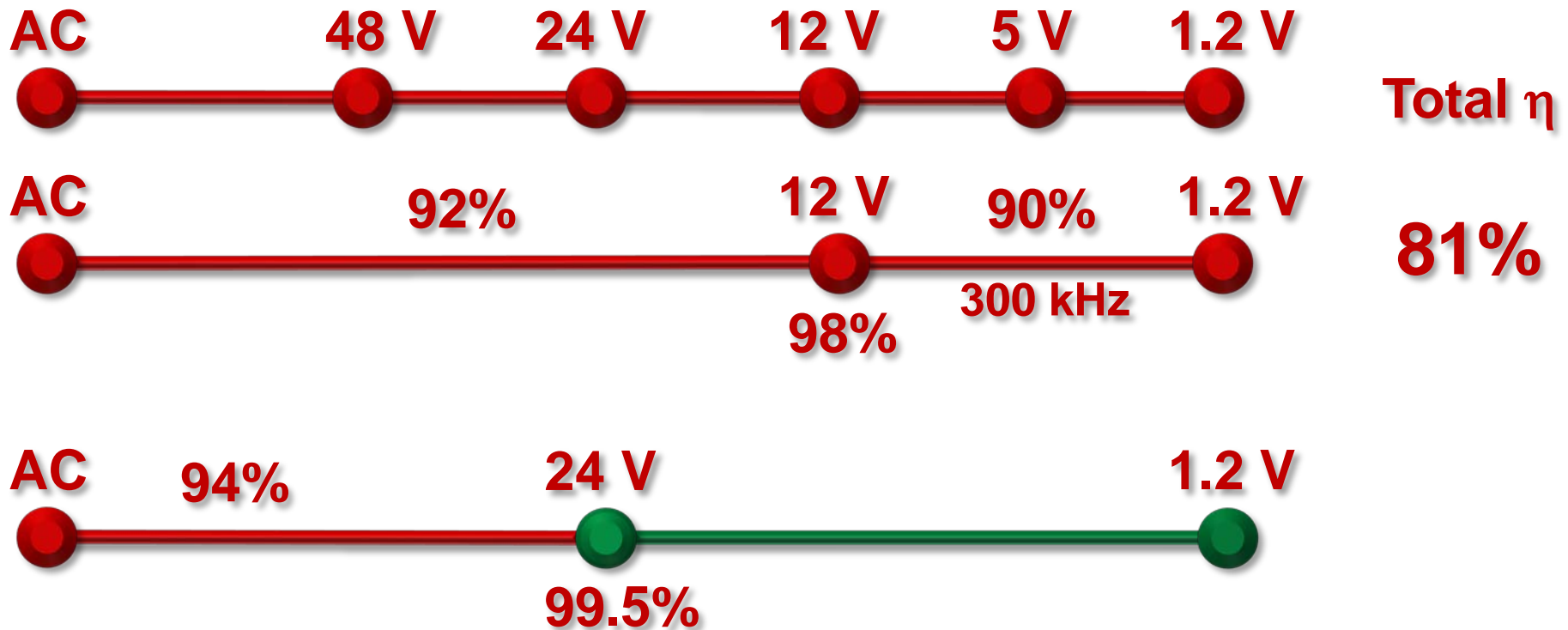
eGaN FETs vs Power MOSFETs



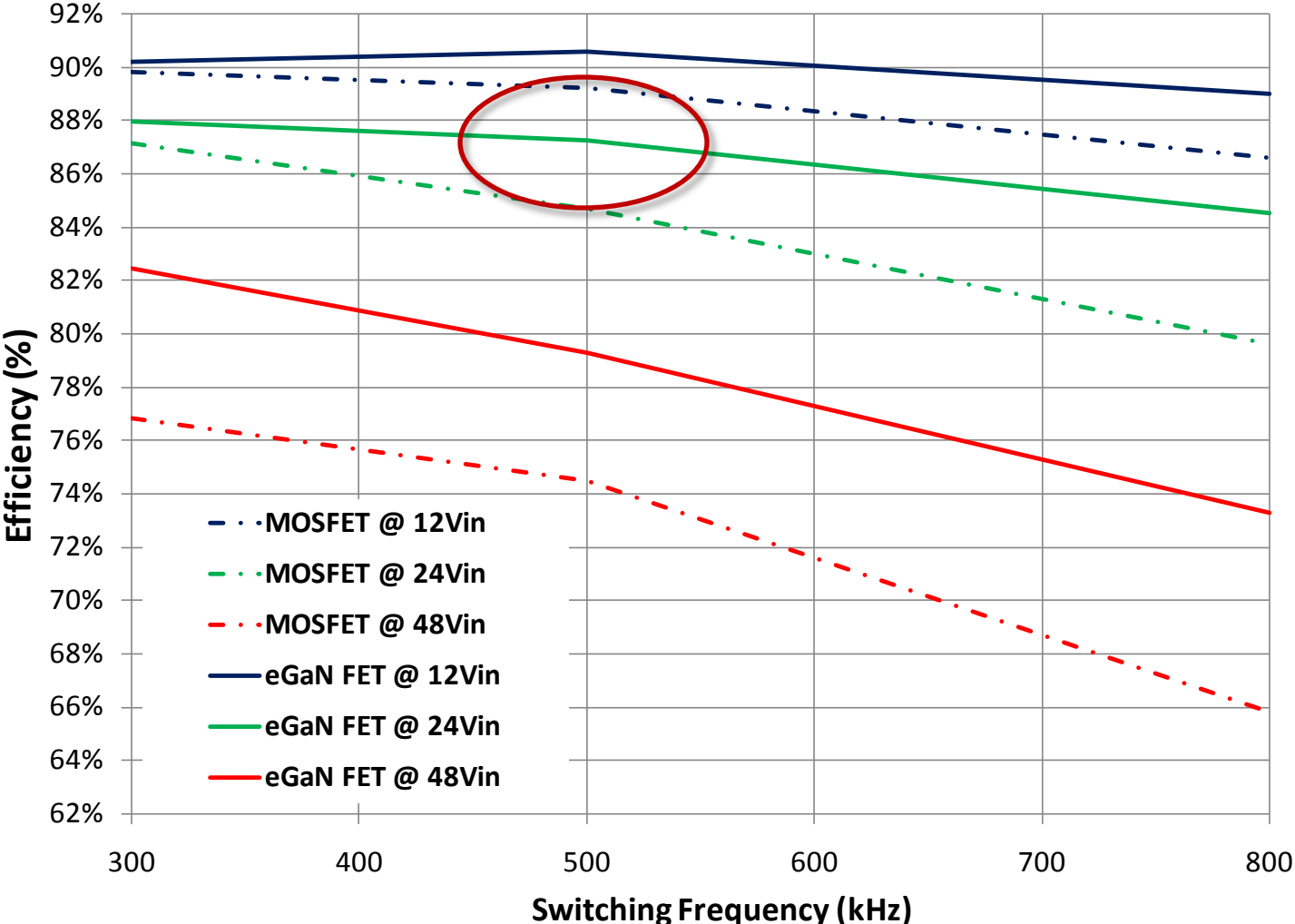
Efficiency vs V_{IN} @ $V_{OUT} = 1.2\text{ V} / 5\text{ A}$



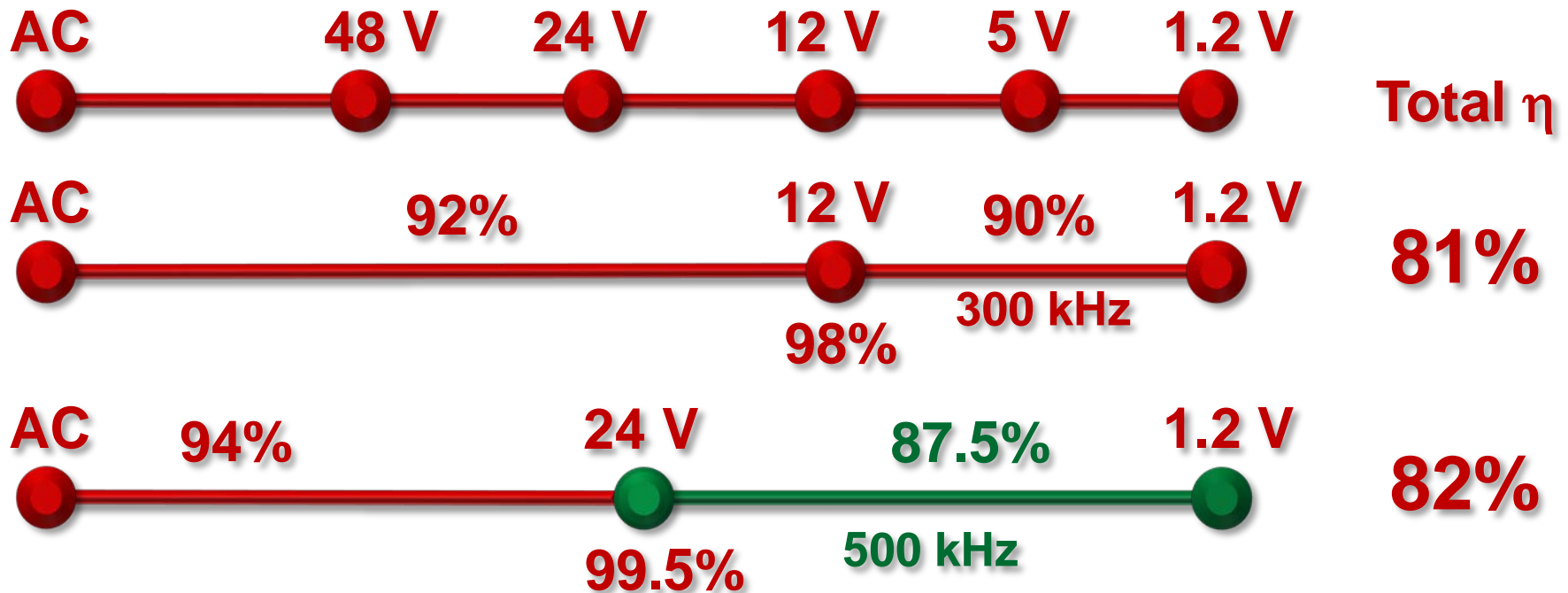
eGaN FETs vs Power MOSFETs



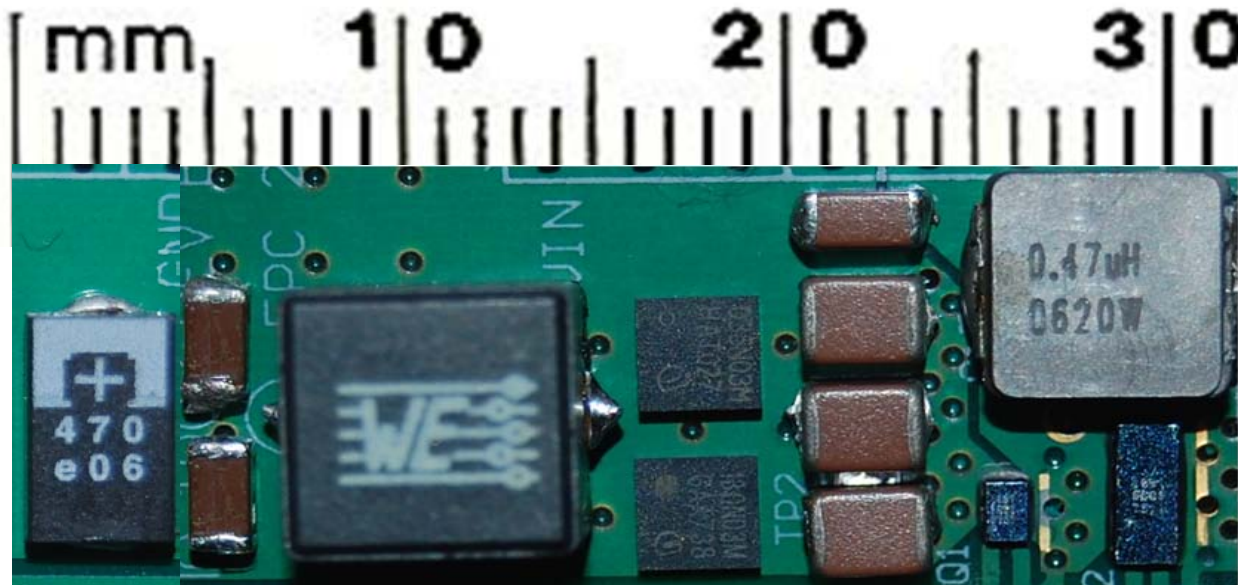
Efficiency vs Frequency @ 1.2Vout / 5A



eGaN FETs vs Power MOSFETs



Buck Size Comparison



		Q1		Q2					
	V_{DS} (V)	$R_{DS(on)}$ (max) High Side	Q_{gd} (typ) High Side	$R_{DS(on)}$ (max) Low Side	Q_g (typ) Low Side	Q_{gs} (typ) Low Side	Q_{sw} (max) Low Side	V_{SO} (typ) 10A, 25°C	Total Package Area (nom)
eGaN FET	40	16 mΩ	0.55 nC	4 mΩ	11.6 nC	18.5 nC	0 nC	2.15 V	8.5 mm ²
MOSFET	30	15 mΩ	1.5 nC	4.3 mΩ	27 nC	32 nC	20 nC	0.76 V	21.8 mm ²

A 24V-1.2V Buck converter was built with both with eGaN FETs and state-of-the-art silicon power MOSFETs

Buck Size Comparison

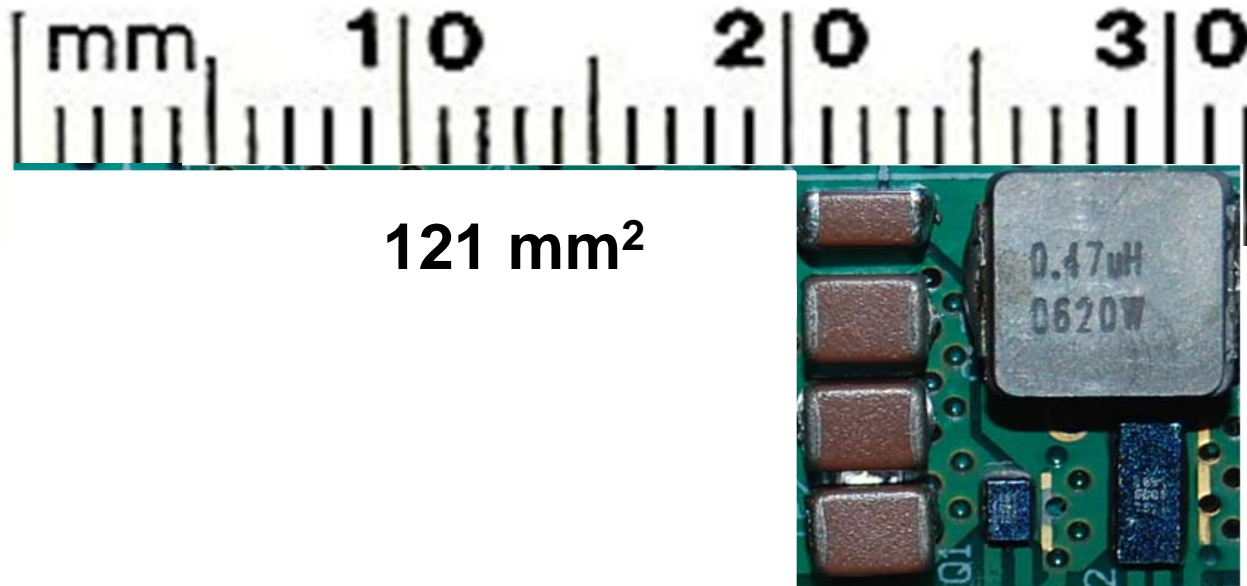


184 mm²



		Q1		Q2					
	V _{DS} (V)	R _{DS(on)} (max) High Side	Q _{gd} (typ) High Side	R _{DS(on)} (max) Low Side	Q _g (typ) Low Side	Q _{oss} (typ) Low Side	Q _{sw} (max) Low Side	V _{SO} (typ) 10A, 25°C	Total Package Area (nom)
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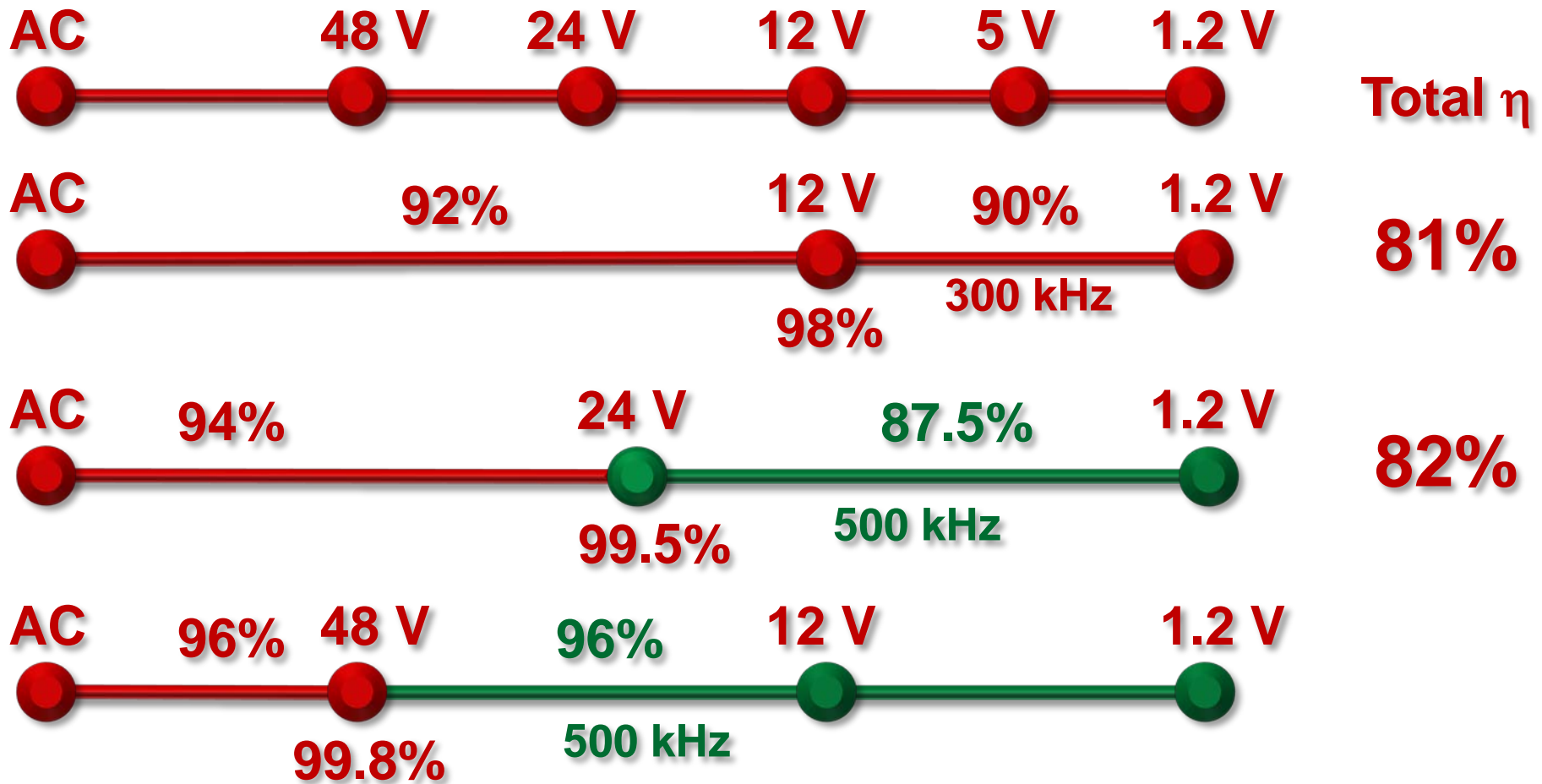
Buck Size Comparison



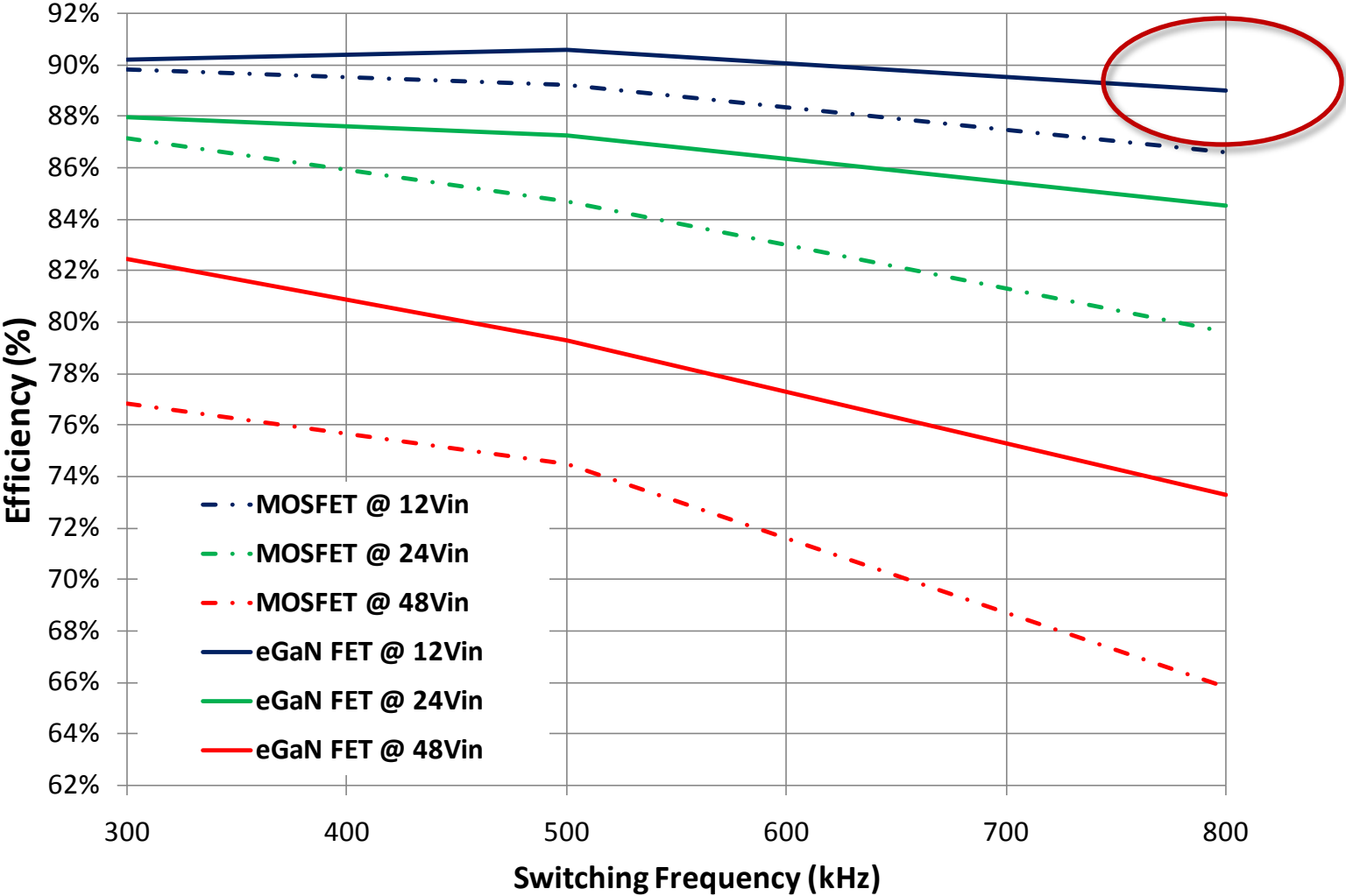
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A 24V-1.2V Buck converter with eGaN FETs is 50% smaller and has 25% less power losses at 800 kHz.

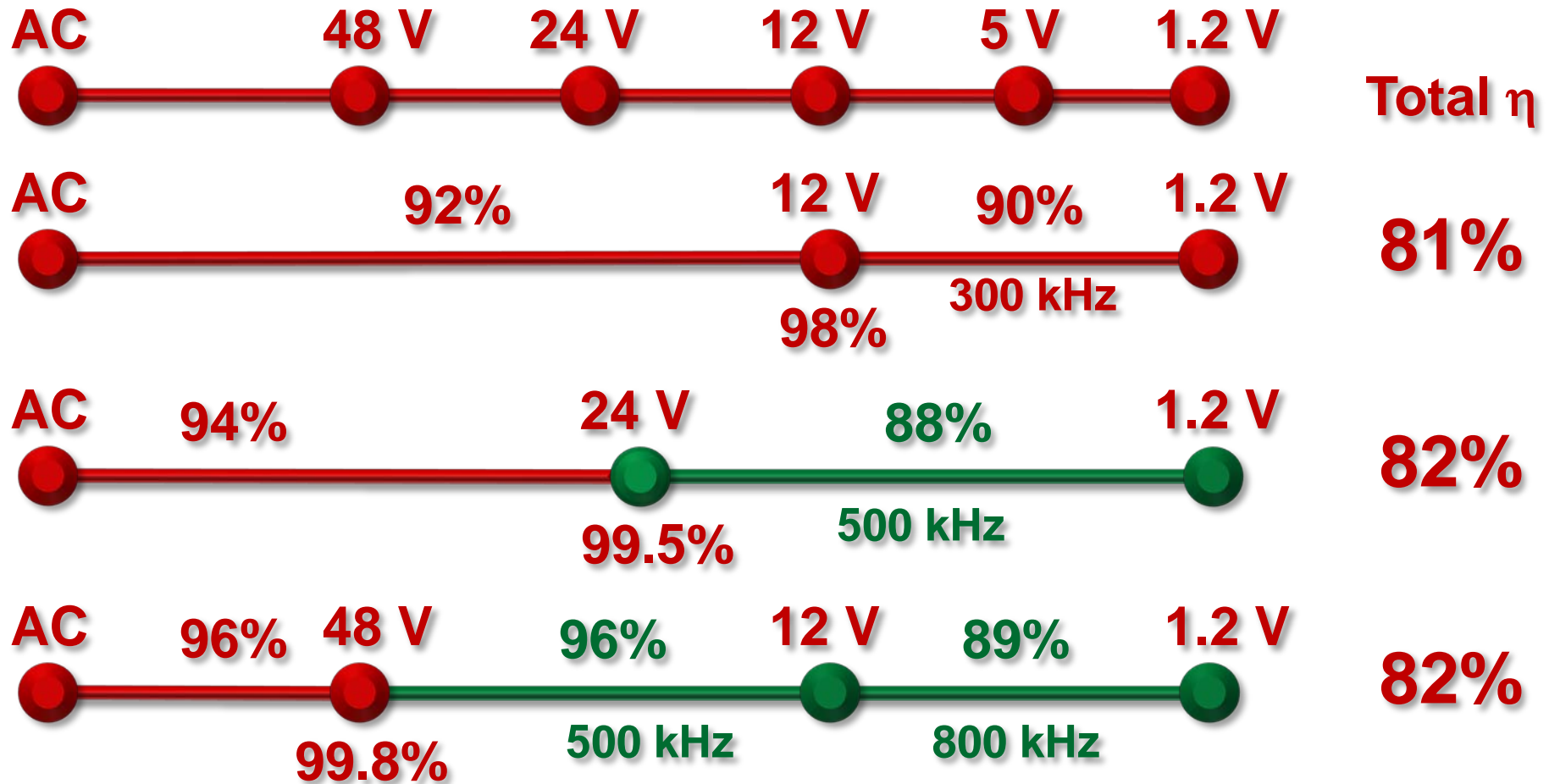
eGaN FETs vs Power MOSFETs



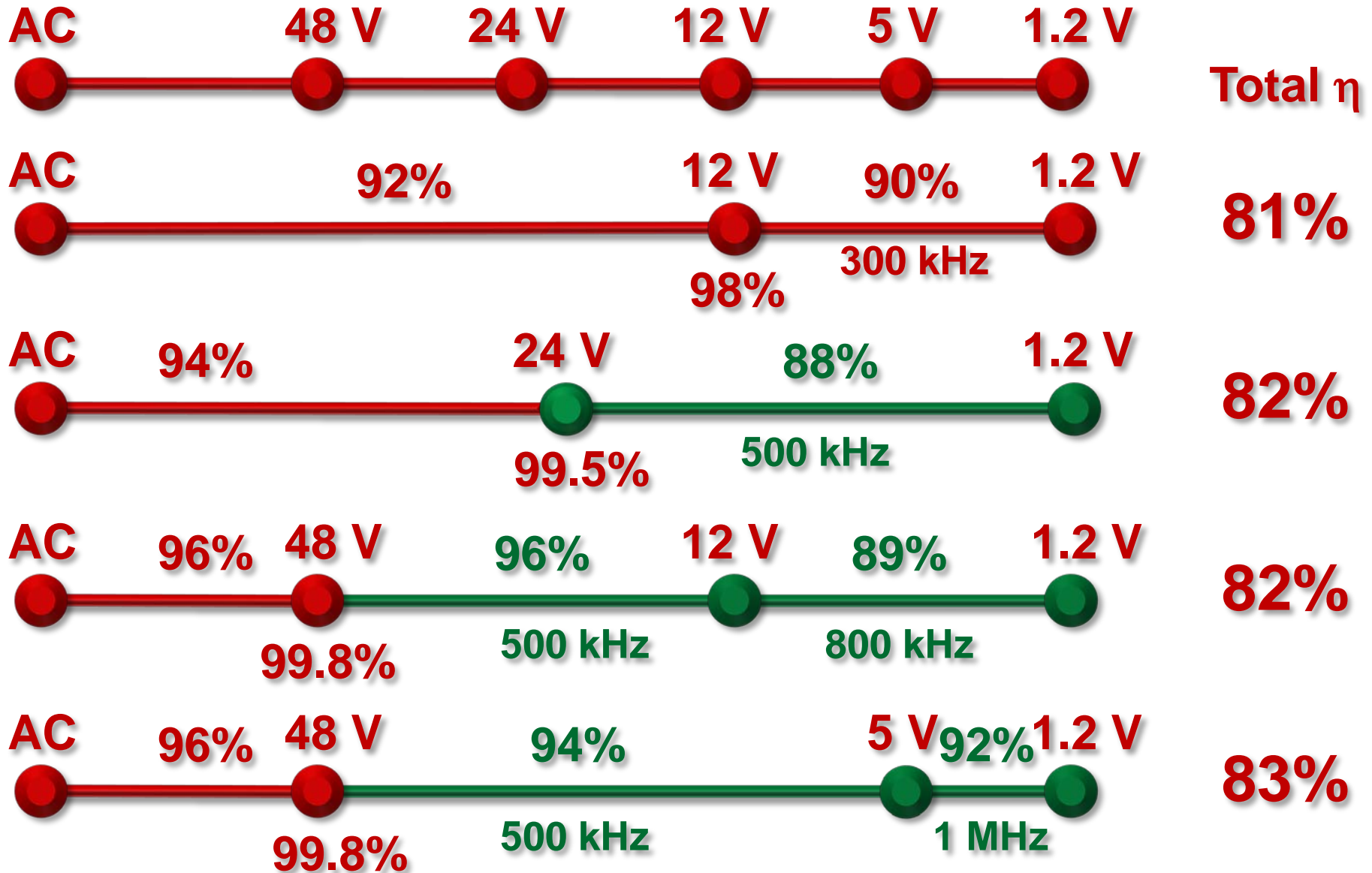
Efficiency vs Frequency @ 1.2Vout / 5A



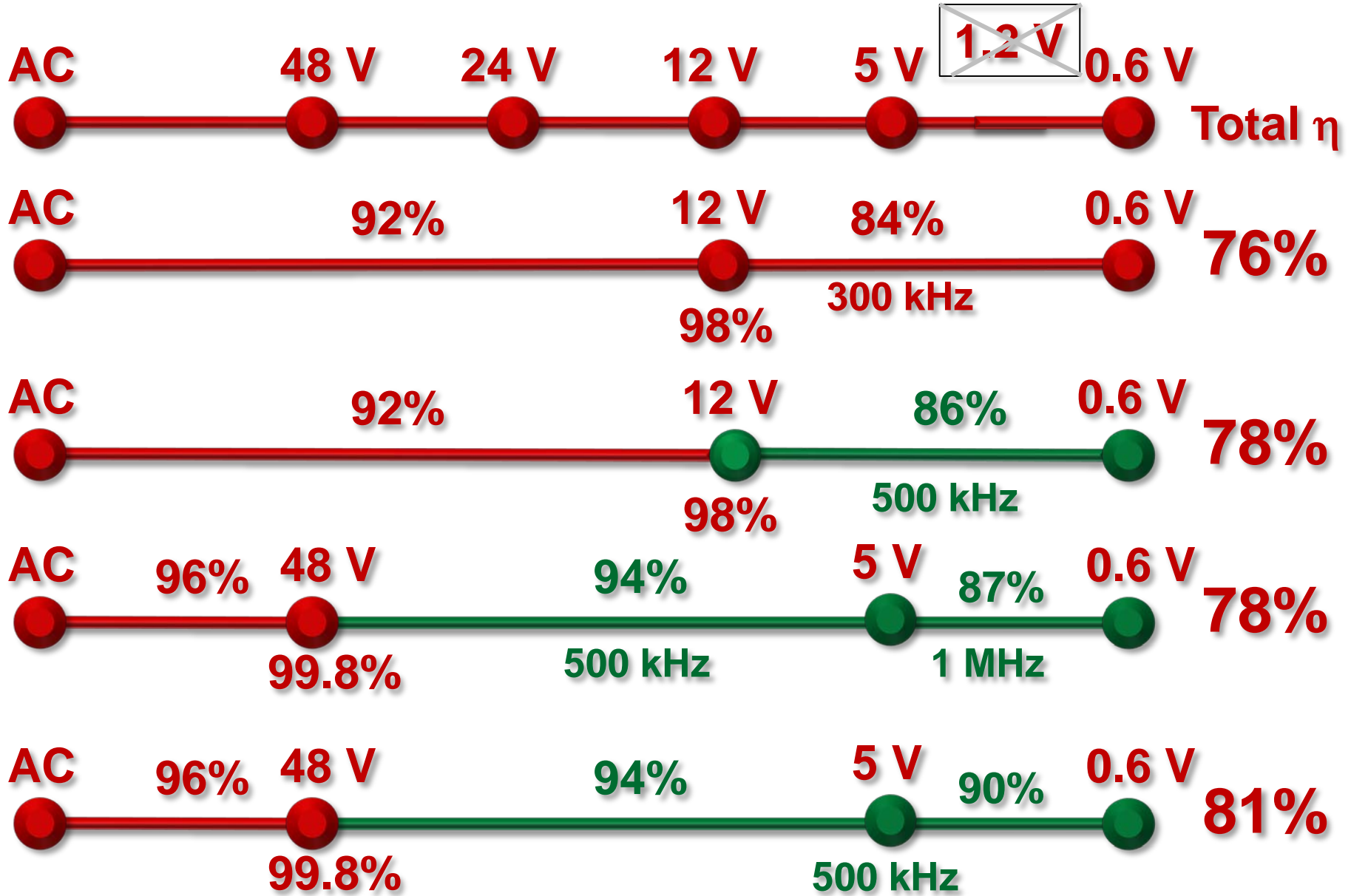
eGaN FETs vs Power MOSFETs



eGaN FETs Enable New Architecture Design

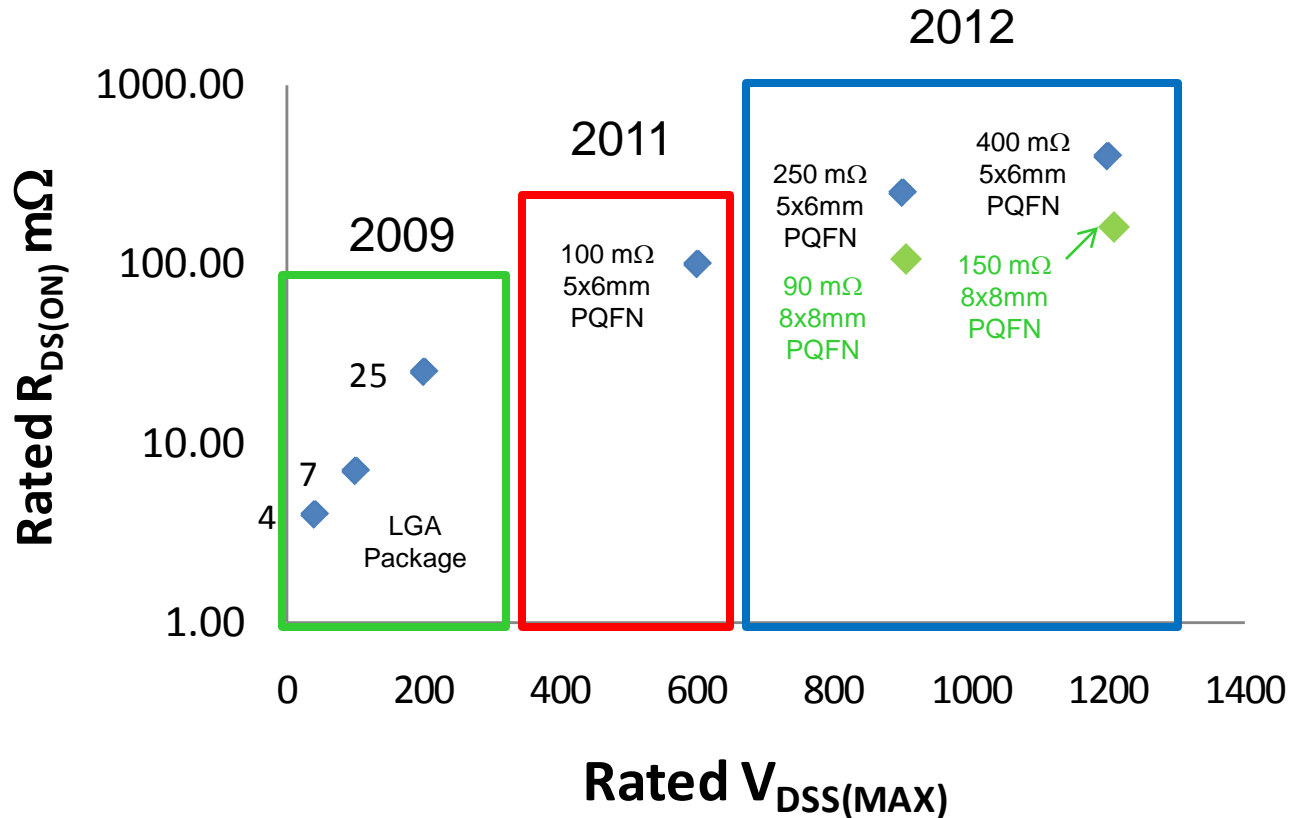


eGaN FETs Improve Efficiencies at Digital Output Voltages



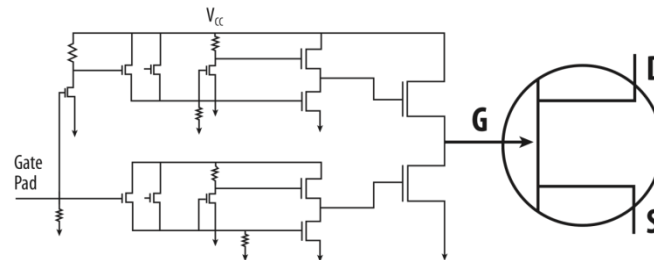
EPC Product Plans

Beyond 600 Volts

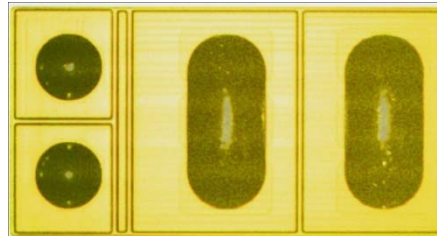


EPC's eGaN FET products will extend to 600V in 2011 and to 900V and 1200V in 2012 if there is adequate customer interest

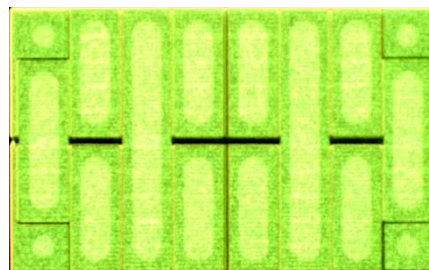
Driver On Board



Discrete FET with Driver



Full-Bridge with Driver



- **Enhancement mode gallium nitride on silicon (eGaN[®]) technology opens up a new set of options for improving overall system efficiency.**
- **Power loss reductions of better than 10% can be realized today with improved transient response and improved power density**
- **As digital voltages continue to decline, the advantages of eGaN FETs compared with silicon, increases**
- **In the future, eGaN technology will allow even higher power density and cost reductions through higher levels of integration.**



*The end of the road
for Silicon ...*

*... is the beginning
of the GaN journey!*